

François RIEUTORD
francois.rieutord@cea.fr



Characterization tools @ IRIG

2020
7th edition

24 novembre 2020



> IRIG= Interdisciplinary Research Institute of Grenoble (IRIG)



- About 1000 people involved in fundamental research, with subjects ranging from health, biology, chemistry, cryogenics to physics.

- 5 departments and 10 labs.



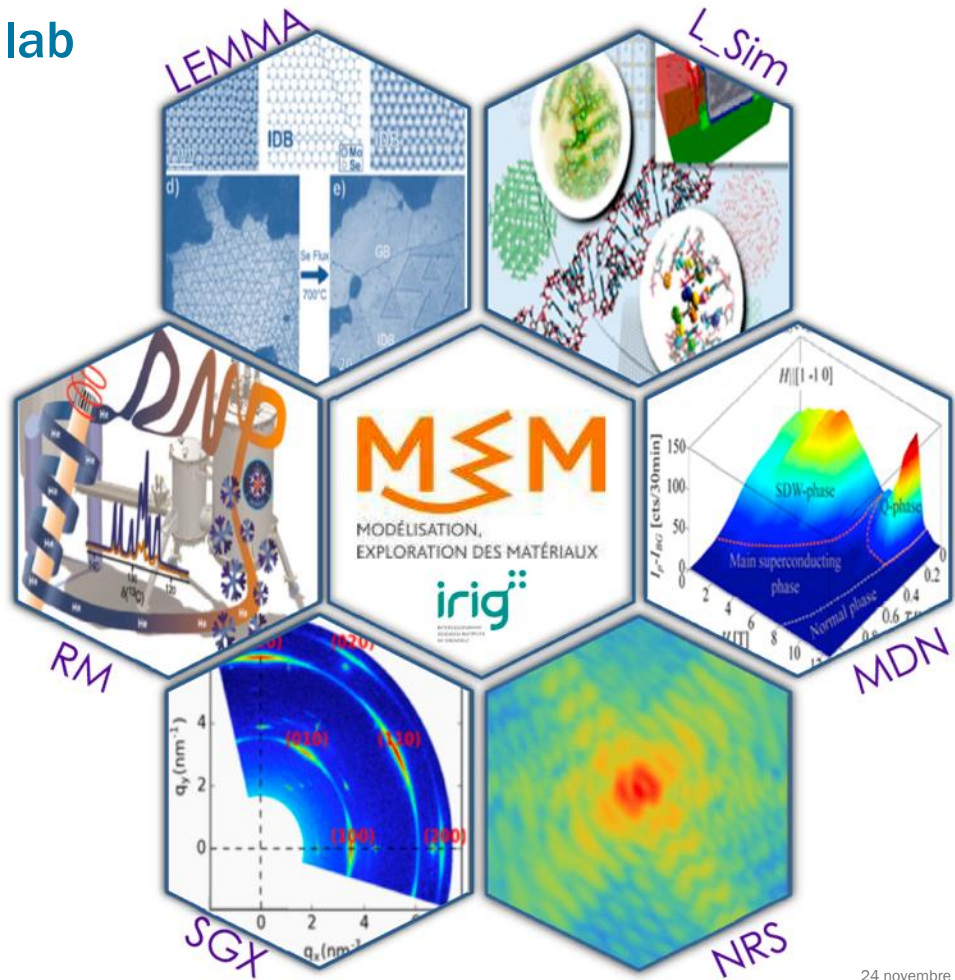
- The MEM lab (within the Physics Department) groups the characterization teams (mostly in the field of material sciences)



Key figures of the MEM lab

60p in 6 teams: experts in different techniques for materials characterization

- Ab initio simulation (LSIM)
- Electron microscopy team (LEMMA)
- Magnetic resonance (RM)
- X-ray scattering (powder, single crystal, reflectivity) (SGX)
- Synchrotron and neutron @ CRG beamlines
- NRS: Synchrotron (grazing angle techniques, reflectivity) Strain measurements
- MDN: Neutrons (inelastic and magnetic scattering)



1 - FIB-SEM nano- tomography

from LEMMA team

@ PFNC (coll. LETI, LITEN and CMTC)

(PH Jouneau and coll.)

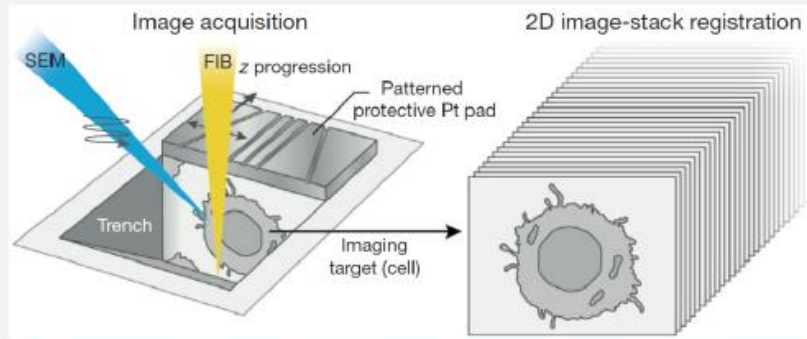
2 - Scanning MicroLaue diffraction

from NRS team

@ ESRF on a BM - CRG beamline (coll. CNRS)

(JS Micha, O. Robach, S. Tardif, O. Ulrich and coll.)

1- FIB-SEM nano-tomography: principle



The sample is cut slice by slice, and each slice is imaged, automatically

- **Acquisition conditions**

FIB : Ga⁺, 30 kV, milling current 700 pA

SEM : SE & BSE images at low voltage (~ 1.5 kV) : no charging effect, good spatial resolution in BSE

- **Ultimate spatial resolution**

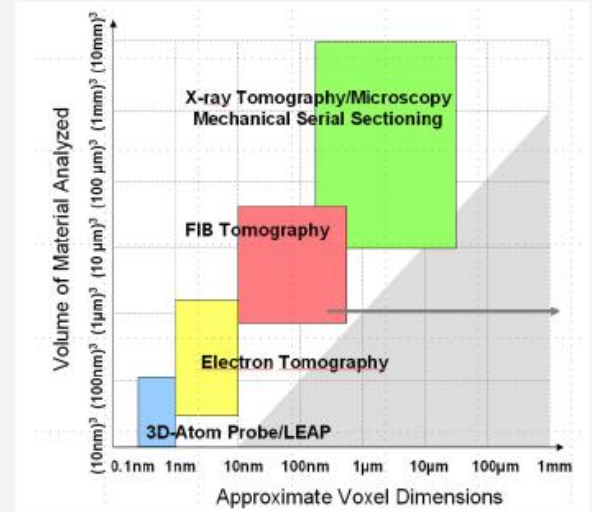
x, y : ~ 2 nm resolution in secondary or backscattered electron images

z : Thinnest possible slice ~ 2 to 3 nm (<< beam size)

→ 3D volumes with with iso-voxels

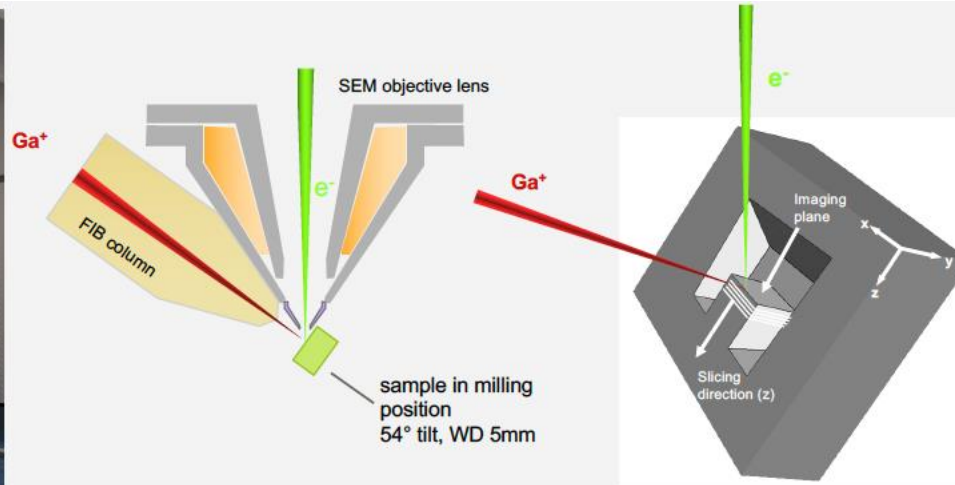
- **Acquisition time : SNR-limited collection time**

~ 1'-2' for each slice → 5 to 60 hours for a volume (± automatically !)





Zeiss XB 550



Focused Ion Beam / Scanning Electron Microscopy

- SEM : surface imaging
 - FIB : surface milling
- | Automated iterative cycles

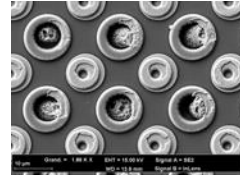
Several instruments @ PFNC: 3 FIB-SEM currently running

1 - FIB-SEM nano-tomography:

Applications, recent developments and perspectives @PFNC

Applications

- *Semiconductor doped layer*
- *Interconnects*
- *PV and Optoelectronic devices*



IR photodiode pixel array

Developments/perspectives

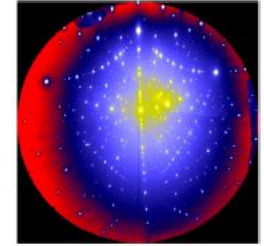
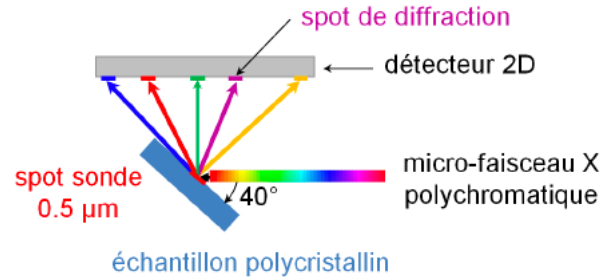
- **Cryogenic sample holder (2019): Quorum sample stage**
 - Reduced damage at low T
- **Compressed sensing (2020)**
 - Faster acquisition /Easier data handling
- **Replacement of one Ga-FIB by Gallium-free sample preparation FIB (Plasma FIB?) (2021) (in collaboration with CMTC)**
 - Less sample damage (Ga contamination / alloying)
 - Faster ion milling

CEA-IRIG and CNRS run 5 CRG beamlines at ESRF

- BM or Wiggler beamlines
- Several instruments to perform X-ray scattering or X-ray spectroscopy (XANES, EXAFS, ...)
- ESRF-> allow the use of high energy X-rays suited to
 - buried system
 - real samples, or in-situ/operando measurements with sample environment.

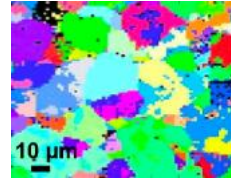
2 - MicroLaue setup on the ESRF CRG-IF BM32 beamline

- Principe: shine a micro(nano) multi-wavelength beam to the sample

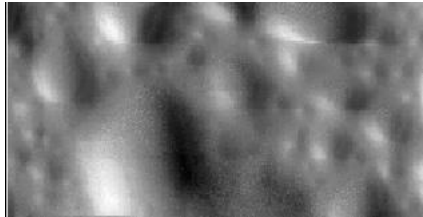


- Full use of the whole spectrum from BM-> **flux**
- No need to rotate the sample, control the rotation angle etc... -> **fast**
- Full info in one (short) exposure (full image -> all components of the shear strain tensor in one shot at one place)

Scanning beam/sample-> imaging ->

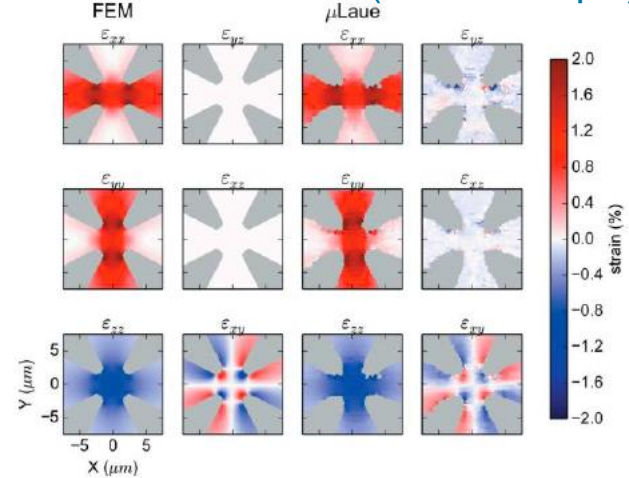


100*50μm image of microcracks
(contrast: ϵ_x)



(coll. SOITEC)

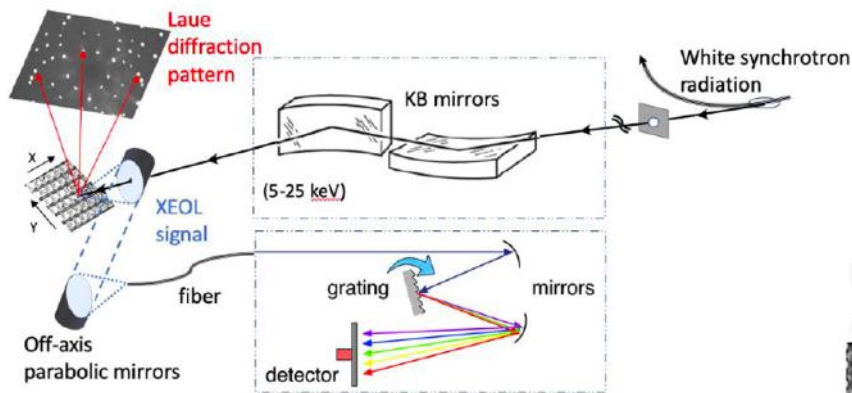
Strained Ge membrane (cross shape) of Ge



(coll. S.Tardif, V. Reboud, V. Calvo)

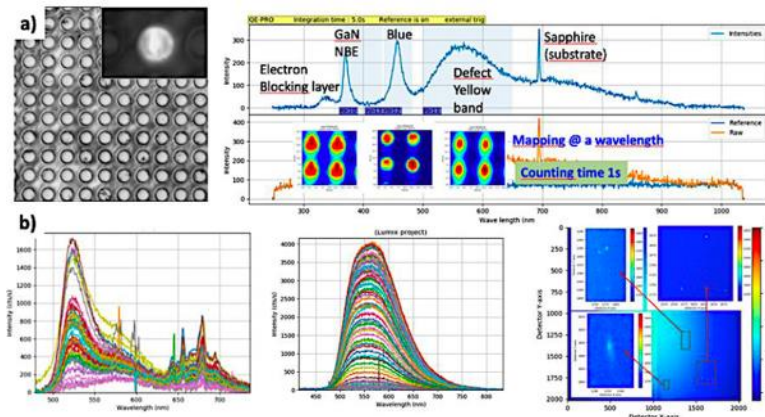
2 - Scanning Micro-Laue setup: example

Combine X-ray scattering with light collection



Array of GaN LED emitters

-> correlate material structural information (strain, composition) to optical properties (light emission, XEOL)



(courtesy: J. Eymery)

24 novembre 2020

New developments:

- High speed scanning micro-Laue
- Possibility to combine with other techniques: fluorescence, XEOL, ..
- 3D mapping
- Improved resolution (down to 100x100nm) thanks to EBS
- Improved data treatment software(LaueTools, notebooks, etc..)



Thank you for your attention

Contacts:

FIB SEM at LEMMA:

Pierre Henri Jouneau:

pierre-henri.jouneau@cea.fr

NMR:

michel.bardet@cea.fr or (DNP)

gael.depaepe@cea.fr

X-ray characterization (SGX) (single crystal, powder, SAXS etc..:)

stephanie.pouget@cea.fr

LSIM: Ab initio simulation DFT, etc

luigi.genovese@cea.fr

NRS Synchrotron : BM32. Jean-Sébastien Micha
(MicroLaue)

micha@esrf.fr

joel.eymeri@cea.fr

Neutrons MDN:

raymond@ill.eu

Whole LAB : Thierry Deutsch

(thierry.deutsch@cea.fr) (Head of the MEM lab)

Any questions: myself :

francois.rieutord@cea.fr

Web site:

<http://www.mem-lab.fr>

Thank you for your attention



This work was funded by the French national program 'programme d'Investissements d'Avenir' IRTNanoelec' ANR-10-AIRT-05.



www.irtnanoelec.fr
[@irtnanoelec](https://twitter.com/irtnanoelec)
[#nanoelec](https://www.instagram.com/nanoelec)